

## Appointment

---

**From:** Beck, Nancy [/O=EXCHANGELABS/OU=EXCHANGE ADMINISTRATIVE GROUP (FYDIBOHF23SPDLT)/CN=RECIPIENTS/CN=168ECB5184AC44DE95A913297F353745-BECK, NANCY]  
**Sent:** 3/1/2019 4:58:01 PM  
**To:** Bertrand, Charlotte [Bertrand.Charlotte@epa.gov]  
**Subject:** Meeting w/ Semiconductor Industry Association  
**Location:** 3130 WJC EAST  
  
**Start:** 3/1/2019 7:00:00 PM  
**End:** 3/1/2019 7:45:00 PM  
**Show Time As:** Tentative

SIA represents the manufacturers of semiconductors and is based in DC. Attached is the letter we submitted seeking the meeting this Friday at 2 pm eastern.

The SIA membership list is considerable, and includes virtually the entire sector (as will be detailed more thoroughly in a handout we will bring with us). In the meantime, an abbreviated list of SIA members include:

Global Foundries	IBM
IDT	INTEL
Marvell	MICRON
Texas Instruments	Western Digital
Qorvo	Qualcomm

We expect to have the following individuals present for the SIA Meeting with Alex Dunn. The list may grow somewhat -- and I will advise as soon as I have additional names. We also expect certain representatives from member companies might want to dial in.

- David Isaacs, Semiconductor Industry Association
- Stephen Harper, Intel
- John Currier, Intel
- Lawrence Cullen, Arnold & Porter

Our Agenda will include:

Introducing the SIA membership generally

Discussing the role the semiconductor industry fills in the US economy

Describing why SIA is interested in regulatory activity which is overseen by OCSP

SIA members are involved in new chemicals innovation but generally are not chemical manufacturers

SIA member acquire and use chemical formulations from their suppliers in the US and overseas

Making Alex aware of the manner in which chemical substances are safely used at semiconductor manufacturing facilities in the US (we will have photos/handouts on this)

Identifying and discussing with Alex various areas of particular interest to SIA members which include

TSCA rulemakings on substances used in manufacturing (e.g., NMP, various solvents) and SIA's role in assisting in these efforts

New Chemicals/PMN, LVE and SNUR requirements (the formulations used by SIA members often contain "new" chemicals) subject to TSCA Section 5 reviews

New Chemicals "Categories" of concern and SIA's efforts to assist in data generation to address data gaps (e.g., photo-acid generators/PAG chemicals)

SIA Members' voluntary efforts to phase out use of PFOA, and OCSPP's role in regulating substances within the PFAS family of substances